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APPLICATION NO.	FI	LING DATE	, F	IRST NAMED INVENTOR	ATTORNEY	Y DOCKET NO.	CONFIRMATION NO.	
09/819,621 03/29/2001		Kenji Todori		P 280037 T7K0-00S105-1 4396		4396		
909	7590 10/01/2003			EXAMINER				
PILLSBURY WINTHROP, LLP P.O. BOX 10500						ANGEBRANNDT, MARTIN J		
MCLEAN, VA 22102					AR	ART UNIT PAPER NUMBE		
·						1756		

DATE MAILED: 10/01/2003

Please find below and/or attached an Office communication concerning this application or proceeding.

•	* _			\mathcal{W}
		Application No.	Applicant(s)	
		09/819,621	TODORI ET AL.	
	Office Action Summary	Examiner	Art Unit	
		Martin J Angebranndt	1756	
	- The MAILING DATE of this c mmunicati			
eriod fo				
THE N - Exten after S - If the - If NO - Failur - Any re	PRTENED STATUTORY PERIOD FOR F MAILING DATE OF THIS COMMUNICAT sions of time may be available under the provisions of 37 of SIX (6) MONTHS from the mailing date of this communicat period for reply specified above is less than thirty (30) days period for reply is specified above, the maximum statutory e to reply within the set or extended period for reply will, by the ply received by the Office later than three months after the dipatent term adjustment. See 37 CFR 1.704(b).	ION. CFR 1.136(a). In no event, however, may a repion. s, a reply within the statutory minimum of thirty period will apply and will expire SIX (6) MONT a statute, cause the application to become ABA	oly be timely filed (30) days will be considered timely. HS from the mailing date of this communication (35 U.S.C. § 133).	ation.
1)⊠	Responsive to communication(s) filed o	n <i>24 Julv 2003</i> .		
2a)⊠		This action is non-final.		
3)	Since this application is in condition for		ers, prosecution as to the meri	ts is
• —	closed in accordance with the practice ι on of Claims			
4)⊠	Claim(s) 1-28 is/are pending in the appli	cation.		
4	a) Of the above claim(s) is/are wi	thdrawn from consideration.		
5)	Claim(s) is/are allowed.			
6)⊠	Claim(s) <u>1-28</u> is/are rejected.			
7)	Claim(s) is/are objected to.			
8)	Claim(s) are subject to restriction	and/or election requirement.		
pplication	on Papers			
9)[] 7	he specification is objected to by the Exa	aminer.		
10) 🔲 🏾	The drawing(s) filed on is/are: a)	•		
	Applicant may not request that any objection			
11)[_] 7	The proposed drawing correction filed on		sapproved by the Examiner.	
40)[] =	If approved, corrected drawings are required	•		
,	The oath or declaration is objected to by t	ne Examiner.		
	nder 35 U.S.C. §§ 119 and 120			
,—	Acknowledgment is made of a claim for f	oreign priority under 35 U.S.C. §	119(a)-(d) or (f).	
a)L	☐ All b)☐ Some * c)☐ None of:			
	1. Certified copies of the priority docu			
	2. Certified copies of the priority docu	·	·	
	 Copies of the certified copies of the application from the Internation ee the attached detailed Office action for 	nal Bureau (PCT Rule 17.2(a)).	_	
14)∐ A	cknowledgment is made of a claim for do	mestic priority under 35 U.S.C. §	119(e) (to a provisional applic	ation).
	☐ The translation of the foreign language.cknowledgment is made of a claim for do			
ttachment	•	, ,	· ·	
) 🔲 Notice	e of References Cited (PTO-892) e of Draftsperson's Patent Drawing Review (PTO-9- nation Disclosure Statement(s) (PTO-1449) Paper I	48) 5) Notice of In	ummary (PTO-413) Paper No(s) formal Patent Application (PTO-152)	<u> </u>

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1. The response provided by the applicant has been read and given careful consideration.

Responses to the arguments are presented after the first rejection to which the argument is directed. Rejection of the previous office action not repeated below are withdrawn based upon the arguments and amendments of the applicant.

- 2. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
 - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 3. Claims 1-5,7-14,16-19 and 21-28 are rejected under 35 U.S.C. 103(a) as being unpatentable over Iida et al. EP 0580346, in view of Murray et al., "synthesis and Charachotrization of nearly monodisperse CdE (E=s,se,te) semiconductor nanocrystallites", JACS, Vol. 115(19) pp. 8706-8715 (1993), Spanel et al. '910 or Liz-Marzan, et al. WO 99/291934.

Iida et al. EP 0580346 teaches a high density optical disk with a shutter layer of semiconductor particles dispersed in a glass or polymeric matrix over coated with a reflective layer as shown in figure 2. Useful semiconductor materials in amounts of 1-80 mol % and having sizes of 0.1 to 50 nm are disclosed. (3/11-33) The use of polymers as the matrix materials, including PMMA, polycarbonate, polystyrenes, polyolefins, and epoxies is disclosed as its the formation of the layer from a solvent based solution. (3/34-41 and 4/3-13). The reflective layer may be various metals including Ag, Au, Al and Cu. (4/44-51). The use of protective layer is also disclosed. (4/52-57). Another embodiment is shown in figure 3.

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Spanel et al. '910 teaches semiconductor particles in a polymeric matrix, where ligands are used to bond to the surface of the particles to stabilize the particles and then polymerized to form a matrix. useful particles are disclosed. 2/22-29). The ligands bonding to the surface of the particles and them undergoing polymerization, including silanes and the like are disclosed. (2/66-3/45).

It would have been obvious to one skilled in the art to modify the article of Iida et al. EP 0580346 by using the processes of Spanel et al. '910 to form the particles alone or in their matrix with the benefit of increasing the stability of the dispersion and uniformity of the particles.

The examiner notes that claims 6, 15 and 20 specifically include the instance where the organic group is part of the polymer. The specification indicates that the organic group may be part of a larger molecule (page 22/lines 17-19) and the polymer may be formed by reaction of organic compounds (22/26-23/3), but discloses that it is preferred that the polymer is not covalently bound to the semiconductor particles due to the possibility of impurities (23/11-16). Based upon the disclosure, the examiner interprets the broad claims embrace the organic group being part of the polymer until the claims particularly specify otherwise. Please note that claims 6,15 and 20 are not rejected under this heading. The examiner notes that the claims do not exclude coated semiconductor particles as comprising language is used in the claims and therefore the semiconductor particles can be coated or not. To exclude this embodiment, the applicant likely would have to limit the composition of the semiconductor particle using "consisting of" language.

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4. Claims 1-28 are rejected under 35 U.S.C. 103(a) as being unpatentable over Iida et al. EP 0580346, in view of Murray et al., "synthesis and Charachotrization of nearly monodisperse CdE (E=s,se,te) semiconductor nanocrystallites", JACS, Vol. 115(19) pp. 8706-8715 (1993) and Liz-Marzan, et al. WO 99/291934.

Murray et al., "synthesis and Charachotrization of nearly monodisperse CdE (E=s,se,te) semiconductor nanocrystallites", JACS, Vol. 115(19) pp. 8706-8715 (1993), teaches the synthesis of nanocrystalline semiconductor particles to reduce polydispersity and improve the uniformity of surface derivitazation (capping). (page8706, right column) The ease of dispersal in various solvents (alkanes, aromatrics, long chain alcohols, etc) is disclosed. (page 8707, left column). The use of these in optical is disclosed. (page 8706, left column)

Liz-Marzan, et al. WO 99/291934 teaches methods for stabilizing particles to prevent agglomeration/coalescence without affecting their properties.(2/16-22). The ligands which bond to the surface of the particles may be thiols, amines, phosphines, phosphates, borates, carboxylates, silicates, siloxy, ... (3/10-28). The stabilization of CdS and other semiconducor materials, having sizes of less than 100 nm, preferably less than 40 nm is disclosed. (7/24-8/17 and examples) The use of this technique for stabilizing the particles for optical uses in a variety of matrices, including polymers, is disclosed. (13/18-23).

It would have been obvious to one skilled in the art to modify the article of Iida et al. EP 0580346 by using the processes of either Murray et al., "synthesis and Charachotrization of nearly monodisperse CdE (E=s,se,te) semiconductor nanocrystallites", JACS, Vol. 115(19) pp. 8706-8715 (1993) with a reasonable expectation of gaining in monodispersity and stability in both solvents and the polymeric matrix based upon the teachings of Murray et al., "synthesis and

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Charachotrization of nearly monodisperse CdE (E=s,se,te) semiconductor nanocrystallites", JACS, Vol. 115(19) pp. 8706-8715 (1993) and Liz-Marzan, et al. WO 99/291934 of the desirability of stabilizing the particles in either solvents or polymeric matrices.

The rejection is based upon the combination of references, not any one of the references alone, therefore piecemeal analysis cannot hope to obviate the rejection.

Applicant's amendment necessitated the new ground(s) of rejection presented in this Office action. Accordingly, **THIS ACTION IS MADE FINAL**. See MPEP § 706.07(a). Applicant is reminded of the extension of time policy as set forth in 37 CFR 1.136(a).

A shortened statutory period for reply to this final action is set to expire THREE MONTHS from the mailing date of this action. In the event a first reply is filed within TWO MONTHS of the mailing date of this final action and the advisory action is not mailed until after the end of the THREE-MONTH shortened statutory period, then the shortened statutory period will expire on the date the advisory action is mailed, and any extension fee pursuant to 37 CFR 1.136(a) will be calculated from the mailing date of the advisory action. In no event, however, will the statutory period for reply expire later than SIX MONTHS from the date of this final action.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Martin J Angebranndt whose telephone number is 703-308-4397.

The examiner can normally be reached on Mondays-Thursday and alternate Fridays.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Mark Huff can be reached on 703-308-2464. The fax phone numbers for the

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organization where this application or proceeding is assigned are 703-872-9310 for regular communications and 703-872-9311 for After Final communications.

Any inquiry of a general nature or relating to the status of this application or proceeding should be directed to the receptionist whose telephone number is 703/308-0661.

Martin J Angebranndt Primary Examiner Art Unit 1756

September 29, 2003